IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of: Kiyoshi IRINO

Serial Number: 09/428,052

Group Art Unit: 2815

Filed: October 27, 1999

Examiner: R. Diaz - 23 - 2

For: METHOD OF FABRICATING A SEMICONDUCTOR DEVICE CONTAINING NITROGEN IN A GATE OXIDE FILM

PETITION FOR EXTENSION OF TIME

Commissioner for Patents Washington, D.C. 20231

January 9, 2002

Sir:

Applicant petitions the Commissioner of Patents and Trademarks to extend the time for response to the Office Action dated August 9, 2001, for two months from November 9, 2001 to January 9, 2002.

Attached please find a check in the amount of \$400.00 to cover the cost of the extension. In the event that any additional fees are due in connection with this paper, please charge our pepeint Account No. 01-2340. This paper is filed in triplicate.

Respectfully submitted,

ARMSTRONG, WESTERMAN & HATTORI, LLP

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Stephen G. Adrián Attorney for Applicant

Registration No. 32,878

Atty. Docket No. 970901A

1725 K Street, N. W., Suite 1000 Washington, D. C. 20006

Tel: (202) 659-2930

Fax: (202) 887-0357

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